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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

PRIORITY Application Serial No. .... 09/507,193

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Inventor..... Mark Fischer et al.

Assignee ..... Micron Technology, Inc.

PRIORITY Group Art Unit ..... 1765

PRIORITY Examiner ..... D. Deo

Attorney's Docket No. ..... MI22-1777

Title: Semiconductor Processing Methods of Forming a Conductive  
Projection and Methods of Increasing Alignment Tolerances

Preliminary Amendment to Accompany the filing of a Continuation  
Application Under 37 C.F.R. 1.53(b)

To: Patent Application  
Assistant Commissioner for Patents  
Washington, D.C. 20231

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Sir:

This is a preliminary amendment accompanying a Request for  
Continuation Application for the above-entitled patent application. Prior to  
examining the application, please enter the amendments and consider the  
remarks contained herein.